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B.L.

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

U.S. PTO  
10/053201  
01/15/02

**Priority** Application Serial No. .... 09/717,476  
**Priority** Filing Date ..... November 20, 2000  
Inventor..... Harry Rosenberg  
Assignee ..... Honeywell International Inc.  
**Priority** Group Art Unit ..... 2818  
**Priority** Examiner ..... P. Dang  
Attorney's Docket No. .... 34593 CON.1  
Title: Tantalum Sputtering Target and Method of Manufacture

**INFORMATION DISCLOSURE STATEMENT**

**PURSUANT TO 37 C.F.R. §§ 1.56, 1.97 AND 1.98**


In compliance with 37 C.F.R. §§ 1.56, 1.97 and 1.98, your attention is directed to the United States patents and other references listed on the attached Form PTO-1449. No admission is made regarding whether all the submitted references are prior art.

The listed references were cited by, or submitted to, the Office in the parent, co-pending application of the above-identified application. The above-identified application is a continuation application of co-pending application Serial No. 09/717,476, filed November 20, 2000. Such prior disclosure is sufficient for the above-identified application as far as copies of the references are concerned. 37 C.F.R. § 1.98(d) and MPEP § 609(2).

Citation of these references is respectfully requested.

Respectfully submitted,

Dated: 15 Jan 2002

By:   
James E. Lake  
Reg. No. 44,854

EL844054843